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Notice of Allowability	Application No.	Applicant(s)	
	10/757,512	SUEHIRO ET AL.	
	Examiner	Art Unit	
	LOHA BEN	2873	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31:	o (OR REMAINS) CLOSED in this ap, or other appropriate communication to the communication in the communication is subject to a subject to the communication is subject to the communication in the communication is subject to the communication in the communication in the communication is subject to the communication in the co	plication. If not include will be mailed in due	ed course. <b>THIS</b>
1. This communication is responsive to <u>Applicants' application</u>	on dated January 15, 2004.		
2. The allowed claim(s) is/are <u>1-9</u> .			
3.   The drawings filed on 04 May 2004 are accepted by the E	xaminer.	4	
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority u a)  All b)  Some* c)  None of the:  1.  Certified copies of the priority documents have 2.  Certified copies of the priority documents have 3.  Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDON'THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.</li> <li>5.  A SUBSTITUTE OATH OR DECLARATION must be submined including changes required by the Notice of Draftsper 1) hereto or 2) to Paper No./Mail Date  (b) including changes required by the attached Examiner Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in</li> </ul>	e been received. e been received in Application No comments have been received in this of this communication to file a reply MENT of this application.  Initted. Note the attached EXAMINER res reason(s) why the oath or declara st be submitted. son's Patent Drawing Review ( PTO 's Amendment / Comment or in the C	national stage applical complying with the red'S AMENDMENT or Nation is deficient.  948) attached  Office action of the gray in the front (not the	quirements
<ol> <li>DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT</li> </ol>	osit of BIOLOGICAL MATERIAL r FOR THE DEPOSIT OF BIOLOGIC	must be submitted. I AL MATERIAL.	Note the
Attachment(s) 1. ☑ Notice of References Cited (PTO-892)	<ol> <li>5. ☐ Notice of Informal F</li> </ol>	Patent Application (PT)	O-152)
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary	(PTO-413),	•
<ul> <li>3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/Paper No./Mail Date 0104;0404;0604</li> <li>4. ☐ Examiner's Comment Regarding Requirement for Deposit</li> </ul>	Paper No./Mail Da 08), 7. 🖾 Examiner's Amendr 8. 🖾 Examiner's Stateme	ment/Comment	owance
of Biological Material	9.	<i>,</i>	
<b>Loha Ben</b> Primary Examiner			

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## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

## In the Claims

In claims 4, 6 and 7: line 2, "residues" has been replaced with – residue --.

Fully amended texts are given below:

- 4. (Currently Amended) The microlens array according to claim 1, wherein the diisocyanate residue[[s]] comprises aromatic diisocyanate residues in an amount of 10 mol% or higher.
- 6. (Currently Amended) The microlens array according to claim 1, wherein the diisocyanate residue[[s]] comprises at least one member selected from the group consisting of a tolylene diisocyanate residue, a 4, 4'—diphenylmethane diisocyanate residue, and a naphthalene diisocyanate residue.
- 7. (Currently Amended) The microlens array according to claim 6, wherein the diisocyanate residue[[s]] comprises a naphthalene diisocyanate residue.

## REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance: None of the references cited teaches or fairly suggests the microlens array of the present invention

wherein the lens array has a resin layer that comprises a cured polycarbodiimide resin described by the formula given in independent claim 1 which contains diisocyanate residue and monoisocyanate residue. Therefore, the present invention distinguishes over the prior art of record.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Loha Ben whose telephone number is (571) 272-2323. The examiner can normally be reached on Monday to Saturday, generally between 12:00 noon and 8:00 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Y. Epps, can be reached on Monday to Friday, at (571) 272-2328. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

December 23, 2004

Loha Ben Primary Examiner